

Electronic Patent Application Fee Transmittal

Application Number:	10522036
Filing Date:	19-Jan-2005
Title of Invention:	Chemically amplified positive photo resist composition and method for forming resist pattern
First Named Inventor/Applicant Name:	Kenji Maruyama
Filer:	Neil S. Bartfeld/Caitlin Yaussi
Attorney Docket Number:	SHIGA7.004APC

Filed as Large Entity

U.S. National Stage under 35 USC 371 Filing Fees

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Basic Filing:				
Pages:				
Claims:				
Claims in excess of 20	1615	2	50	100

Miscellaneous-Filing:

Petition:

Patent-Appeals-and-Interference:

Post-Allowance-and-Post-Issuance:

Extension-of-Time:

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Miscellaneous:				
Total in USD (\$)				100